

XP 402: Long pulse DND plasma development

Presented by D. A. Gates At the NSTX results review Princeton Plasma Physics Laboratory, Princeton NJ 9/20/2004

Outline

- XP goals
- Control system improvements
- High κ plasma developed
- Pulse length and performance
 - Achieved 1MA, 1s pulse
- Improved operational boundaries
- Summary

Control latency reduction

- Identified system latency as primary source of vertical stabilization limits
- Systematically identified latencies and removed them
- Latency now ~1/4 value in 2003
- Also added analog vertical voltage difference measurement



Target shape developed

- Plasma shape control using old control system
 - Used offline
 equilibrium code to
 predict required coil
 currents
- Able to control inner gap by reducing outer squareness
- δ limited to < 0.6



Long pulse DND 1MA, 1s

- ~20% β for ~16 τ_E
- $\kappa \sim 2.3$
- H89P ~ 2.1
- No early Hmode
 - Would likely benefit from early H-mode onset



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Experiment possible due to improved operating regime

- System latency reduced by 1/3
- Major system upgrade
 - New i/o cards
 - New Sky computer
 - New power supply link
 - New operating system
 - Extensive software optimization
- Wider range of I/aB by increasing the breadth of the NSTX operating regime

All EFIT reconstructions 2001-2004 Data filtered on $|d\kappa/dt| < const.$ 2.6 2004 2002-3 2.4 2001 2.2 2.0 1.8 1.6 1.4 0.6 0.8 1.2 0.4 1.0 1.4 1.6 1.8

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Operating regime broadened substantially

- Simulataneous doubling of β_t (pulse averaged) and 50 % increase in normalized pulse length
- Increase correlates strongly with high κ





Summary

- Control system latency reduced (x1/4) impressive effort by control team
 P. Mercele, T. Gibney, D. Mestrovite, G. P.
 - R. Marsala, T. Gibney, D. Mastrovito, G. Rossi
- Latency reduction has increased $\kappa \sim 20-30\%$
- 1MA, 1s plasma produced
- Increased $\kappa \Rightarrow$ increased pulse length (x1.5) and β (x2) simultaneously for long pulse discharges